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Summary of Experimental Stations

About 57 experimental stations are operated at the PF storage ring, the PF-AR and the slow positron facility (SPF), as shown in Figs. 1, 2 and 3. 36 stations are dedicated to research using hard X-rays, 16 stations for studies in the VUV and soft X-ray energy regions, and 5 stations for studies using slow positrons. Tables 1, 2 and 3 summarize the areas of research carried out at the experimental stations at the PF storage ring, PF-AR and SPF. The specifications in terms of the optics and performance of each experi-

mental station differ according to experimental requirements and methodology. Tables 4, 5 and 6 list the details of the optics of the hard X-ray stations, the soft X-ray / VUV stations and the slow positron stations. The principal performance parameters, including energy range, energy resolution, beam-spot size, and photon flux at the sample position for PF and PF-AR, and energy range, pulse width, frequency, and positron flux for SPF are shown.

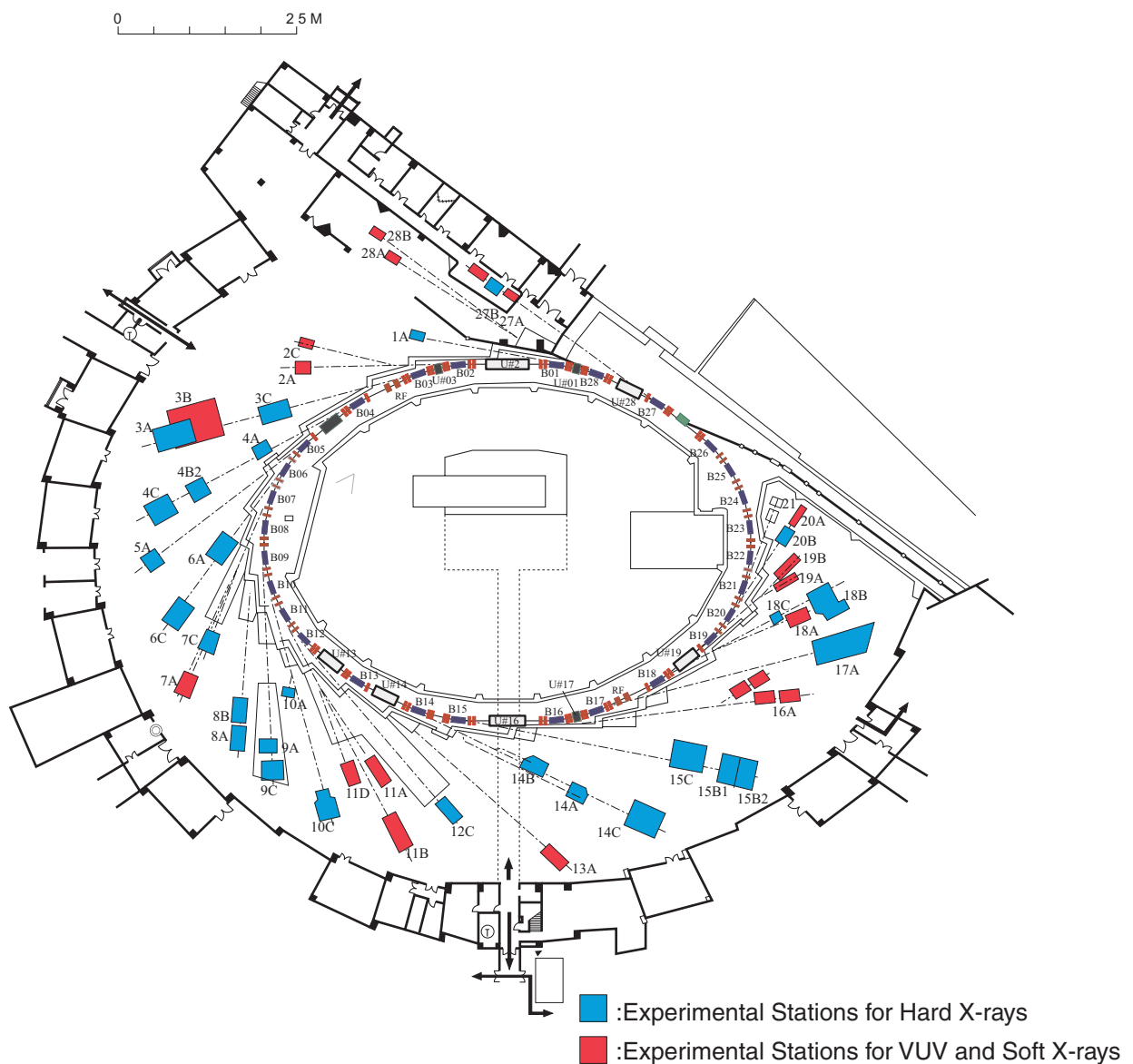


Figure 1: Plan view of the PF experimental hall, showing hard X-ray experimental stations (blue), and VUV and soft X-ray experimental stations (red).

Table 1: List of experimental stations at the PF storage ring.

Experimental Station		Person in Charge
BL-1	(Short Gap Undulator) A Macromolecular crystallography	N. Matsugaki
BL-2	(Undulator) A* Soft X-ray spectroscopy C* Soft X-ray spectroscopy	Y. Kitajima J. Adachi
BL-3	(A: Short Gap Undulator) A X-ray diffraction and scattering station for materials science B VUV and soft X-ray spectroscopy(◇) C Characterization of X-ray optical elements/White X-ray magnetic diffraction	H. Nakao H. Kato [Hiroasaki Univ.], A. Yagishita K. Hirano
BL-4	A Trace element analysis, X-ray microprobe B2 High resolution powder diffraction(♣) C X-ray diffraction and scattering	A. Iida T. Ida [Nagoya Inst. Tech.], H. Nakao Y. Yamasaki
BL-5	(Multipole Wiggler) A Macromolecular crystallography	Y. Yamada
BL-6	A Small-angle X-ray scattering C X-ray diffraction and scattering(♣)	N. Igarashi S. Sasaki [Tokyo Inst. Tech.] H. Kawata
BL-7	A Soft X-ray spectroscopy(◇) C X-ray spectroscopy and diffraction	J. Okabayashi [RCS], K. Amemiya H. Sugiyama
BL-8	A Weissenberg camera for powder/Single-crystal measurements under extreme conditions B Weissenberg camera for powder/Single-crystal measurements under extreme conditions	R. Kumai R. Kumai
BL-9	A XAFS C XAFS	H. Abe H. Abe
BL-10	A X-ray diffraction and scattering C Small-angle X-ray scattering	Y. Yamasaki N. Shimizu
BL-11	A Soft X-ray spectroscopy B Surface EXAFS, soft X-ray spectroscopy D Characterization of optical elements used in the VSX region	Y. Kitajima Y. Kitajima K. Ito
BL-12	C XAFS	H. Nitani

Experimental Station		Person in Charge
BL-13	(Undulator) A Soft X-ray photoemission spectroscopy and XAFS	K. Mase
BL-14	(Vertical Wiggler) A Crystal structure analysis and detector development B High-precision X-ray optics C Medical applications and general purpose (X-ray)	S. Kishimoto K. Hirano K. Hyodo
BL-15	B1** White X-ray topography and X-ray experiments for general purpose B2** Surface and interface X-ray diffraction C** High-resolution X-ray diffraction	H. Sugiyama H. Sugiyama K. Hirano
BL-16	(Variable Polarization Undulator) A Soft X-ray spectroscopies with circular and linear polarization	K. Amemiya
BL-17	(Short Gap Undulator) A Macromolecular crystallography	Y. Yamada
BL-18	A Angle-resolved photoelectron spectroscopy of surfaces and interfaces(◆) B Multipurpose monochromatic hard X-ray station(◆) C High pressure X-ray powder diffraction (DAC)(♣)	K. Yaji [ISSP], A. Yagishita S. Velaga [India, Saha Institute], N. Igarashi S. Nakano [NIMS], T. Kikegawa
BL-19	(Revolver Undulator) A Spin-resolved photoelectron spectroscopy (Mott detector)(◆) B** Soft X-ray emission spectroscopy(◆)	K. Yaji [ISSP], A. Yagishita K. Yaji [ISSP], A. Yagishita
BL-20	A VUV spectroscopy(◇) B** White and monochromatic beam general-purpose X-ray station(◆)	N. Kouchi [Tokyo Inst. Tech], K. Ito J. B. Aitken [ASCo.], H. Kawata
BL-27	(Beamline for experiments using radioisotopes) A Radiation biology, soft X-ray photoelectron spectroscopy B Radiation biology, XAFS, X-ray diffuse scattering	N. Usami N. Usami
BL-28	(Elliptical / Helical Undulator) A/B High-resolution VUV-SX beamline for angle-resolved photoemission High-resolution VUV-SX spectroscopy	K. Ono

- ♣ User group operated beamline
- ◆ External beamline
- ◇ Operated by University
- * Shutdown at the end of FY2012 for reconstruction
- ** Shutdown at the end of FY2012

RCS: Research Center for Spectrochemistry, the University of Tokyo
ISSP: Institute for Solid State Physics, the University of Tokyo
ASCo.: Australian Synchrotron Co-operation

Table 2: List of experimental stations at the PF-AR.

Experimental Station		Person in Charge
AR-NE1	(Multipole Wiggler)	
A	Laser-heating high pressure X-ray diffraction and nuclear resonant scattering (DAC)	T. Kikegawa
AR-NE3	(Undulator)	
A	Macromolecular crystallography	Y. Yamada
AR-NE5		
C	High pressure and high temperature X-ray diffraction (MAX-80)	T. Kikegawa
AR-NE7		
A	High pressure and high temperature X-ray diffraction (MAX-III), X-ray imaging	K. Hyodo
AR-NW2	(Undulator)	
A	XAFS/Dispersive XAFS/Time-resolved-X-ray diffraction	H. Abe
AR-NW10		
A	XAFS	H. Nitani
AR-NW12	(Undulator)	
A	Macromolecular crystallography	L.M.G. Chavas
AR-NW14	(Undulator)	
A	Time-resolved X-ray diffraction, scattering and absorption	S. Adachi

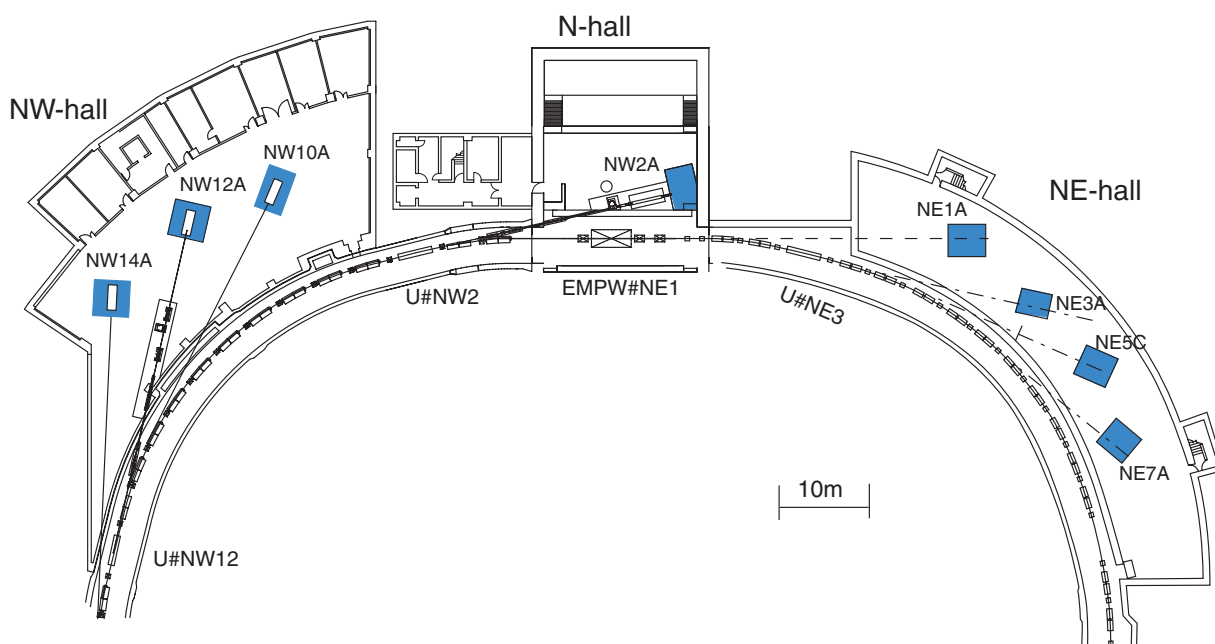


Figure 2: Plan view of beamlines in the PF-AR north-east, north, and north-west experimental halls.

Table 3: List of experimental stations at the Slow Positron Facility.

Experimental Station		Person in Charge
SPF-A1	General purpose	T. Hyodo
SPF-A2	Reflection high-energy positron diffraction	T. Hyodo
SPF-A3	General purpose	T. Hyodo
SPF-B1	General purpose (Positronium negative ion)	T. Hyodo
SPF-B2	Positronium time-of-flight	T. Hyodo

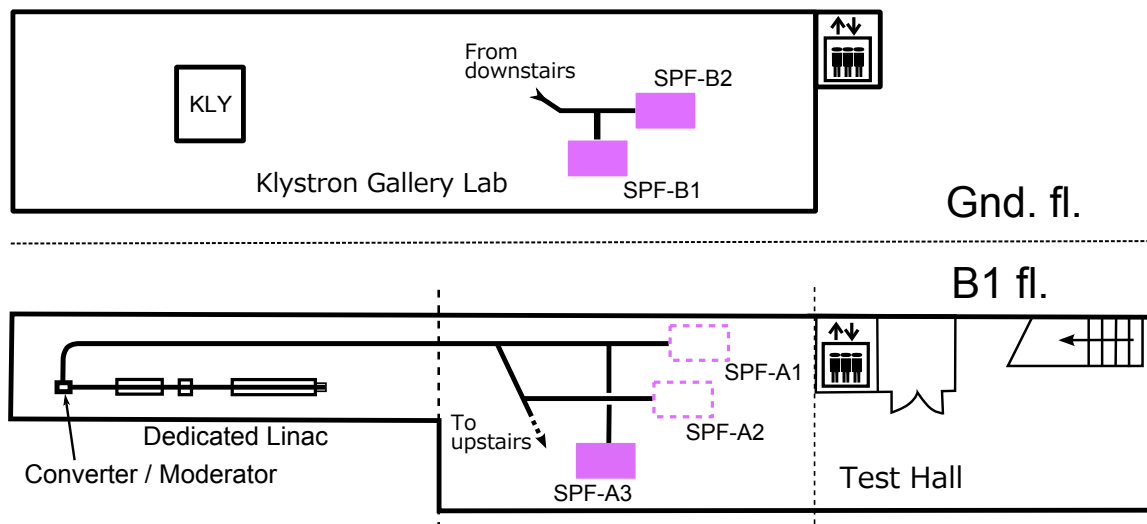


Figure 3: View of beamlines in the Slow Positron Facility.

Table 4: Specifications of X-ray beamline optics.

Branch Beamline	Horizontal Acceptance (mrad)	Type of Monochromator	Mirror	Photon Energy (keV)	Beam Size (H×V) (mm)	Photon Flux at Sample Position (/s)	Energy Resolution ($\Delta E/E$)×10 ⁻⁴	Reference
BL-1A	0.15	Channel-Cut Si(111) Liquid N ₂ Cooling	Bimorph Si Rh-Coated Si Rh-Coated	3.7 ~ 4.5 11.2 ~ 12.9	0.05×0.01	4×10 ¹¹ @11.2 keV (0.025×0.01mm ²)	~2	
BL-3A	1	Flat Double Crystal Si(111)	Bent Cylinder	4 ~ 14	0.7×0.2	6×10 ¹²	~5	1, 2
BL-3C	1.75	Double Crystal Si(111)	None	4 ~ 20 or white	20×6(mono) 0.1×0.1(white)		~2	
BL-4A	6	Double Crystal Si(111)	Vertical Focusing Mirror	4 ~ 20	50×4		~2	3
BL-4B2	4.5	Flat Double Crystal Si(111)	Bent Cylinder	6 ~ 20	13×2		~2	4, 5
BL-4C	2	Flat Double Crystal Si(111)	Bent Cylinder	5 ~ 19	0.7×0.5		~5	6, 7
BL-5A	0.5	Micro-Channel Double Crystal Si(111)	Bent Plane Si Rh-Coated Bent Cylinder Si Rh-Coated	6.5 ~ 17	1.2×0.4	3×10 ¹¹ (0.2×0.2 mm ²)	~2	
BL-6A	2	Bent Crystal Ge(111) ($\alpha = 8.0^\circ$)	Bent Plane ULE	8.3 (fixed)	0.5×0.2	1.0×10 ¹² /mm ² (Slit full-open)	~10	8
BL-6C	2	Flat Double Crystal Si(111)	Bent Cylinder	5 ~ 12 (~25 non-Focus)	1.2×1.2			
BL-7C	4	Double Crystal Si(111) Sagittal Focusing	Double Mirror Fused Quartz Focusing	4 ~ 20 (4 ~ 13)	5×1	1×10 ¹⁰ /6mm ² (8 keV, 300 mA) (1×10 ¹¹ when focused)	~2	9 - 11
BL-8A	2.22	Flat Double Crystal Si(111)	Bent Cylinder	5 ~ 19	0.82×0.52	3.2×10 ¹¹ (12.4keV, 400mA)	~5	12
BL-8B	2.21	Flat Double Crystal Si(111)	Bent Cylinder	5 ~ 19	0.75×0.45	2.2×10 ¹¹ (12.4keV, 400mA)	~5	12

Branch Beamline	Horizontal Acceptance (mrad)	Type of Monochromator	Mirror	Photon Energy (keV)	Beam Size (H×V) (mm)	Photon Flux at Sample Position (/s)	Energy Resolution ($\Delta E/E$)×10 ⁻⁴	Reference
BL-9A	3	Double Crystal Si (111)	Collimating and Focusing Bent Conical Mirrors (Rh-Coated) Double Flat Mirror (Ni-Coated)	2.1 ~ 15	0.5×0.3	6×10 ¹¹ (7keV, 450 mA)	2	13, 14
BL-9C	3.5	Double Crystal Si(111)	Bent Cylinder Rh-Coated Si	4 ~ 23	0.8×0.6	1×10 ¹¹ (8keV, 450 mA)	~2	
BL-10A	1	Si(111), Si(311) Quartz(100) PG(002) Curved Si(111) (α ~ 4°, 8°)	Plane Pt Coated Fused Quartz	5 ~ 25	10×3		10 ~5	15
BL-10C	4	Double Crystal Si(111)	Bent Cylinder	8.3 (fixed)	1.0×0.5	5.0 x 10 ¹¹ (Slit full-open)	2	16
BL-12C	2	Double Crystal Si(111)	Bent Cylinder Double Flat Mirror (Ni-Coated)	4 ~ 23	0.6×0.6	9×10 ¹⁰ (8 keV, 450mA)	~2	17
BL-14A	1.28 (Vertical)	Double Crystal Si (111) Si (311) Si (553)	Bent Cylinder Rh-Coated Fused Quartz	5.1 ~ 19.1 9.9 ~ 35.6 22.7 ~ 84.5	2×1 at focus 5×38		2	18
BL-14B	2.2 (Vertical)	Flat Double Crystal Si(111)	None	10 ~ 57	5×14		2	19
BL-14C	1.96 (Vertical)	Double Crystal Si(111), Si(220)	None	5 ~ 100 or white	6×70		2	20, 21
BL-15B1** B2**	2	Double Crystal Si (111)	Bent Cylinder	5 ~ 20 or white	0.6×0.4	1.0×10 ¹² /mm ² (8 keV, 430 mA)	~2	
BL-15C**	2	Double Crystal Si (111)	None	4 ~ 30	60×6			
BL-17A	0.1 ~ 0.2	Double Crystal Si(111) Liquid N ₂ Cooling	Bent Plane Si Rh-Coated Bent Plane Si Rh-Coated	6 ~ 9 11 ~ 13	0.25×0.04	10 ¹⁰ (12.4 keV, 450mA, 0.02×0.02mm ²)	~2	22, 23

Branch Beamline	Horizontal Acceptance (mrad)	Type of Monochromator	Mirror	Photon Energy (keV)	Beam Size (H×V) (mm)	Photon Flux at Sample Position (/s)	Energy Resolution ($\Delta E/E$)×10 ⁻⁴	Reference
BL-18B [India, DST]	2	Double Crystal Si(111)	Plane and Bent Cylinder	6 ~ 20			~2	
BL-18C	1	Double Crystal Si(111)	Cylinder Fused Quartz Pt-Coated	6 ~ 25	0.07×0.04		~2	
BL-20B** [ASCo.]	2	Channel Cut Si(111) Channel Cut Si(311) Sagittal Focusing Si(111) Double Crystal	None	4.5 ~ 21 10 ~ 36 4.5 ~ 25	25×2 25×1.5 0.6×1		~2 ~1 ~2	24
BL-27B	4	Double Crystal Si(111)	None	4 ~ 20	100×6		~2	25
AR-NE1A	0.28	Micro-Channel Double Crystal Si(111), High-Resolution Channel Cut Si(4,2,2)&(12,2,2)	Bent Plane W/C Multilayer Coated Si	6 ~ 50	0.8×0.2	8×10 ¹¹ (0.2×0.2mm ²)	~2	
AR-NE3A	H:0.2 V:0.1	Double Crystal Si(111) Liquid N ₂ Cooling	Pre-Mirror Bent Flat Si Rh-Coated Post-Mirror Bent Cylinder Fused Quartz Rh-Coated	6.5 ~ 17	0.8×0.2	8×10 ¹¹ (0.2×0.2mm ²)	~2	26, 27
AR-NE5C	3	Double Crystal Si(111)	None	30 ~ 100 or white	60×5		5	28
AR-NE7A	4	Double Crystal Si(111)		25 ~ 50 or white	80×3		5	
AR-NW2A	H:1.0 V:0.2	Double Crystal Si(111) Liquid N ₂ Cooling	Bent Cylinder Si Rh-Coated Bent Flat Si Rh-Coated	5 ~ 25	0.6×0.2 ~10×0.06	6×10 ¹² (12keV, 60mA)	~2	29 - 31

Branch Beamline	Horizontal Acceptance (mrad)	Type of Monochromator	Mirror	Photon Energy (keV)	Beam Size (H×V) (mm)	Photon Flux at Sample Position (/s)	Energy Resolution ($\Delta E/E$) $\times 10^{-4}$	Reference
AR-NW10A	1.2	Si(311)	Pt-Coated Bent Cylinder Double Flat Mirror (Rh-Coated)	8 ~ 42	2.2×0.5	1×10 ¹⁰ (22 keV, 60mA)	~1	32
AR-NW12A	H:0.3 V:0.1	Double Crystal Si(111) Liquid N ₂ Cooling	Pre-Mirror Bent Flat Si Rh-Coated Post-Mirror Bent Cylinder Si Rh-Coated	6.5 ~ 17	1.3×0.3	2×10 ¹¹ (0.2×0.2 mm ²)	~2	33, 34
AR-NW14A	H:0.3 V:0.1	Double Crystal Si(111) Liquid N ₂ Cooling	Bent Cylinder Rh-Coated Bent Flat Rh-Coated	4.9 ~ 25	0.45×0.25	5×10 ¹²	~2	35

** Shutdown at the end of FY2013

ASCo.: Australian Synchrotron Co-operation
India DST: Department of Science & Technology

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Table 5: Specifications of VUV and soft X-ray beamline optics.

Beamline	Acceptance H × V (mrad) or Undulator Parameters	Type of Monochromator	Groove Density (#/mm)	Energy Range (eV)	Beam Size H × V (mm)	Resolving Power (E/ΔE) Photon Flux (photons/s)	Reference
BL-2A* Undulator	K = 0.5 ~ 2.2 $\lambda_u = 6$ cm	Double Crystal InSb (111), Si (111)	—	1740 ~ 5000	< 1φ	2000, 8000 10 ¹¹	1 - 4
BL-2C* Undulator	K = 0.55 ~ 2.2 $\lambda_u = 6$ cm	Varied-Line-Space Plane Grating	1000 2200	250 ~ 1400	0.9 × 0.1	5000 ~ 10000 10 ¹¹ ~ 10 ¹⁰	5 - 7
BL-3B	10 × 2	Grazing Incidence R = 24 m $\alpha + \beta = 165^\circ$ 1800	200 600	10 ~ 280	< 2φ	200 ~ 3000 10 ¹² ~ 10 ⁹	8, 9
BL-7A [RCS]	6 × 1	Varied-Line-Space Plane Grating	300 650	50 ~ 1300	2.5 × 0.5	1000 ~ 9000 10 ¹² ~ 10 ⁹	10
BL-11A	5 × 1	Varied-Line-Space Plane Grating	300 800 1200	70 ~ 1900	2 × 1	500 ~ 5000 10 ¹² ~ 10 ⁹	11 - 14
BL-11B	4 × 0.6	Double Crystal InSb (111), Si (111)		1724 ~ 5000	5 × 2	2000 10 ¹⁰	3 15 - 17
BL-11D	4 × 2	Grazing Incidence Varied Deviation-Angle On-Blaze Mount R ₁ = 52.5 m R ₃ = 22.5 m	2400	60 ~ 245 200 ~ 900	1 × 0.1	2000 10 ¹¹	18, 19
BL-13A Undulator	K _{max} = 8 $\lambda_u = 18$ cm	Variable-Included-Angle Varied-Line-Spacing Plane Grating	300 1000	30 ~ 330 100 ~ 1600	~0.2 × 0.04	4000 ~ 10000 10 ¹² ~ 10 ⁹	20 - 22
BL-16A Undulator	K _{max} = 2.37 (Circular Polarization) K _{max} = 3.12 (Horizontal Linear Polarization) K _{max} = 1.98 (Vertical Linear Polarization) K _{max} = 1.73 (45-deg Linear Polarization) $\lambda_u = 5.6$ cm	Variable-Included-Angle Varied-Line-Spacing Plane Grating	500 1000	250 ~ 1500	~0.2 × 0.1	4000 ~ 8000 10 ¹² ~ 10 ¹¹	23, 24
BL-18A [ISSP]	2 × 2	Grazing Incidence R = 3 m $\alpha + \beta = 160^\circ$ R = 6.65 m $\alpha + \beta = 167.5^\circ$	300 600 1000	15 ~ 150	< 1φ	1000~2000 10 ¹¹ ~ 10 ⁹	25
BL-19A Revolver Undulator [ISSP]	[K = 1.0 ~ 9.0 $\lambda_u = 16.4$ cm K = 0.5 ~ 1.25 $\lambda_u = 5$ cm K = 0.5 ~ 2.5 $\lambda_u = 7.2$ cm K = 1.0 ~ 5.0 $\lambda_u = 10$ cm	Grazing Incidence R = 2 m $\alpha + \beta = 160^\circ$ R = 4 m $\alpha + \beta = 170^\circ$	600 1200 600 1200	12 ~ 250	< 0.7φ	1000 10 ¹²	26, 27
BL-19B** Revolver Undulator [ISSP]	$\lambda_u = 7.2$ cm K = 1.0 ~ 5.0 $\lambda_u = 10$ cm	Varied-Line-Space Plane Grating	800 2400	10 ~ 1200	< 0.5φ	400-4000 10 ¹² ~ 10 ¹¹	28, 29

Beamline	Acceptance H × V (mrad) or Undulator Parameters	Type of Monochromator	Groove Density (#/mm)	Energy Range (eV)	Beam Size H × V (mm)	Resolving Power (E/ΔE) Photon Flux (photons/s)	Reference
BL-20A	28 × 5	3m Normal Incidence	1200 2400	5 ~ 40	2 × 1	300 ~ 30000 10 ¹² ~ 10 ⁸	30
BL-27A	5 × 0.5	Double Crystal InSb (111)		1800 ~ 4000		2000	31
BL-28A/B Helical Undulator	K _x = 0.23 ~ 3 K _y = 0.23 ~ 6 K _y = 0.23 ~ 6	Varied-Line-Space Plane Grating	400	30 ~ 300	0.15 × 0.05	30000 10 ¹²	32

* Shutdown at the end of FY2012 for reconstruction

** Shutdown at the end of FY2012

RCS: Research Center for Spectrochemistry, the University of Tokyo

ISSP: Institute for Solid State Physics, the University of Tokyo

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Table 6: Specifications of the beamlines at Slow Positron Facility.

Beamline	Beam Energy	Pulse Width	Frequency	Intensity	Reference
SPF-A1	100eV - 35keV	1-10ns	≤ 50Hz	5×10 ⁶ e+/s	
SPF-A2	100eV - 35keV	1μs	≤ 50Hz	5×10 ⁷ e+/s	
SPF-A3	100eV - 35keV	1μs	≤ 50Hz	5×10 ⁷ e+/s (5×10 ⁶ e+/s after brightness enhancement)	3,4
SPF-B1	100eV - 35keV	1-10ns	≤ 50Hz	5×10 ⁶ e+/s	1,2,3,4
SPF-B2	100eV - 35keV	1-10ns	≤ 50Hz	5×10 ⁶ e+/s	5,6

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